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**PATENT  
30205/39440**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application of: Geun Su Lee

Serial No.: 10/609,509

Filed: June 30, 2003

### For: Photoresist Composition

Group Art Unit: 2812

Examiner: Amanda C. Walke

I hereby certify that the documents referred to as enclosed therewith are being deposited with the United States Postal Service on as first class mail, in an envelope addressed to: Commissioner for Patents, P.O. Box 1450 Alexandria, Virginia 22313-1450, on **August 20, 2004,**

Michael R. Hally

## AMENDMENT

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Dear Commissioner:

In response to the Office Action mailed on June 29, 2004, please amend the above-identified patent application as follows.

Amendments to the specification and abstract begin on page 2 of this paper.

Amendments to the claims begin on page 3 of this paper.

Remarks in support of an allowance begin on page 6 of this paper.